

Validation of M3D-K code for beam-driven TAE modes

XP -1015

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*et al.***

Goal: *obtain detailed measurements
of structure and dynamics of TAE
modes to validate the M3D-K code*

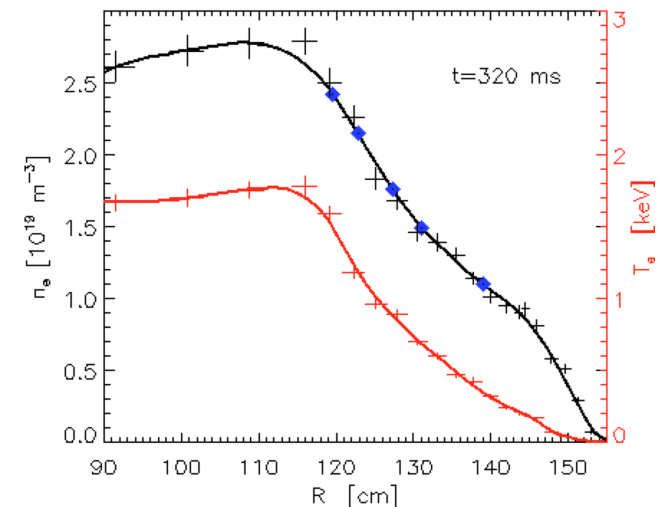
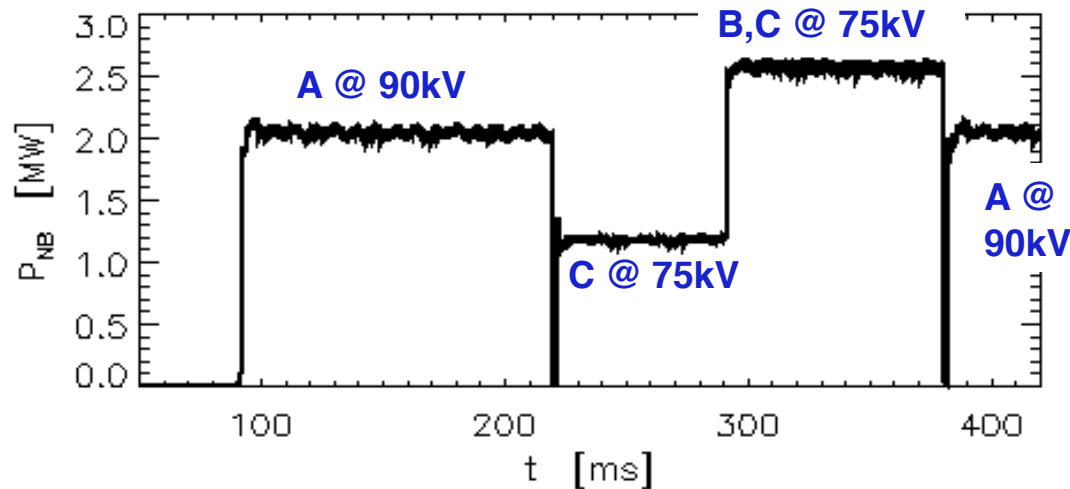
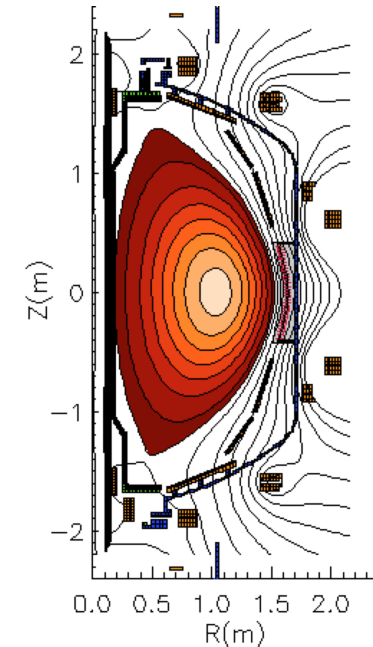
**Allotted run time:
0.5 day**

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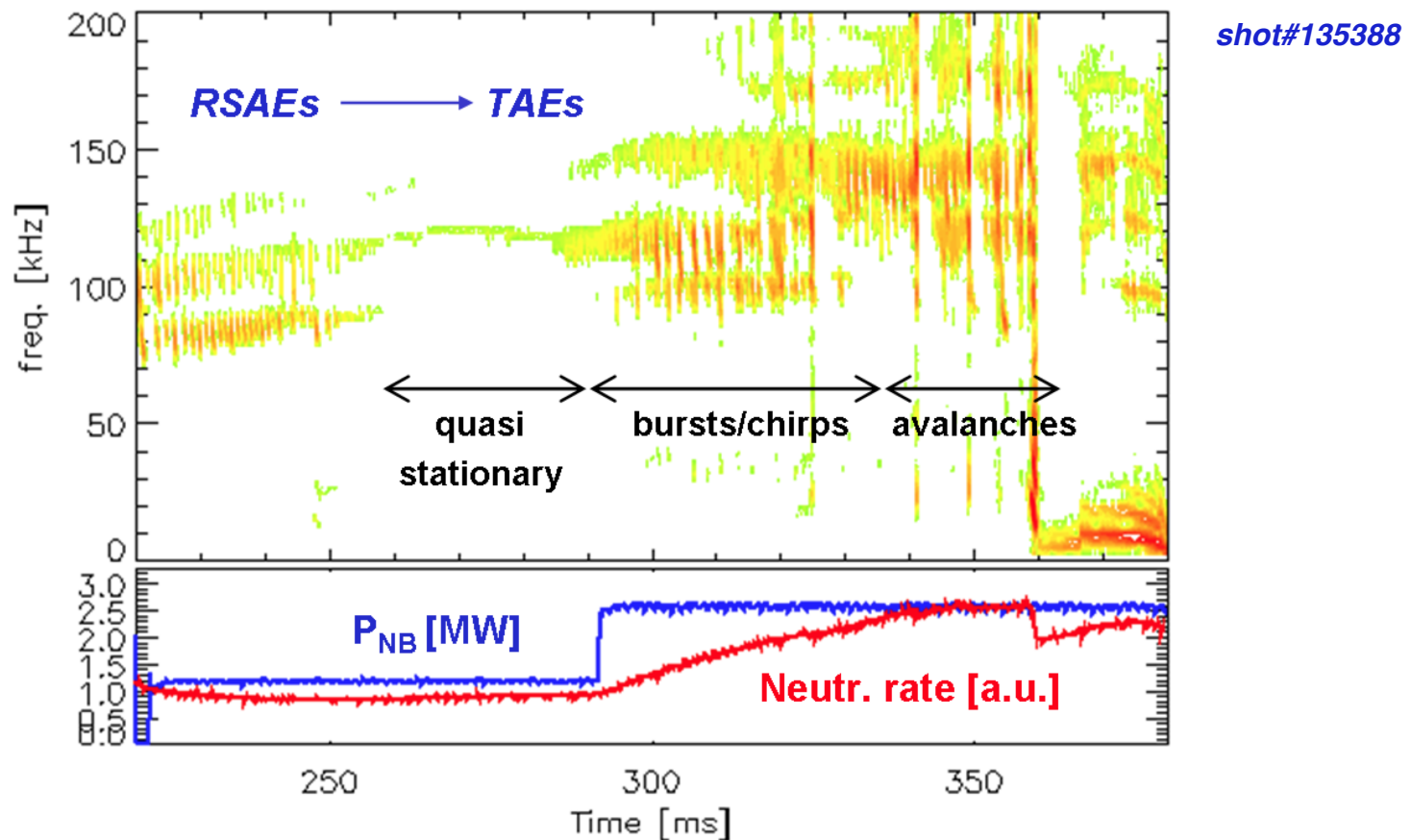
Focus on L-mode, center-stack limited deuterium plasmas (similar to XP-916)

- Starting conditions:
 - Reproduce baseline discharge from 2009 (e.g. sh#135388)
 - L-mode, D plasma, center-stack limited
 - Make sure that plasma remains *limited* from 200 ms up to ~450 ms
 - Need good shot reproducibility
 - LITERs at 10 mg/min total deposition rate



Optimize scenario to have “long” ($\gg 50$ ms) phase with weakly turbulent TAEs

- Scan NB voltage to identify “marginally stable” conditions
- Maximize duration of quasi-stationary TAE phase by adjusting NB timing (example: delay source B)



Run plan for ½ day XP (~12 good shots)

- Re-establish baseline scenario from shot 135388 2 shots
- Optimize density and NB timing/voltage 3 shots
- Document mode structure and TAE dynamics 3 shots (*repeat*)
- Document q -profile evolution (anticipate source A) 4 shots
- Repeat for high density, up to $n \sim 8 \times 10^{19} \text{ m}^{-3}$ @ $t \sim 300 \text{ ms}$ as time permits

Total: ~12 shots

Diagnostics & Machine conditions

- Required diagnostics:
 - BES (at least 8 radial channels), reflectometers
 - All fast ion diagnostics (FIDA, NPA, ssNPA, sFLIP)
 - Plasma profiles (MPTS, CHERS, MSE) & magnetics



- Machine conditions:
 - NB sources B & C used at de-rated voltage, minimum 60 kV
 - Need low impurity level for FIDA; oxygen content must be low
 - Need well reproducible discharges
 - LITERs @ ~10mg/min total